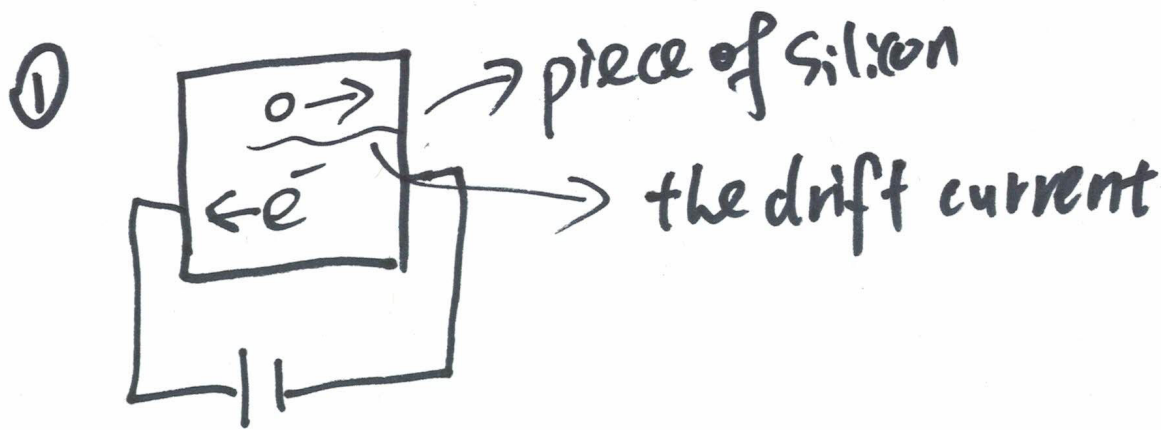


P_p n_p n_n P_n n_i — conc. of electrons and holes
 — intrinsic silicon
 — cm^3
 — at a certain temperature
 — $n_i = 1.5 \times 10^{10} / \text{cm}^3$ at room temp



$V_{p\text{-drift}} = \mu_p \cdot E$ → intensity of the electric field
 ↳ mobility of the holes

$V_{n\text{-drift}} = \mu_n \cdot E$

$\mu_n > \mu_p$

$$\rho = \frac{1}{q(Ln \cdot n + Ap \cdot p)}$$

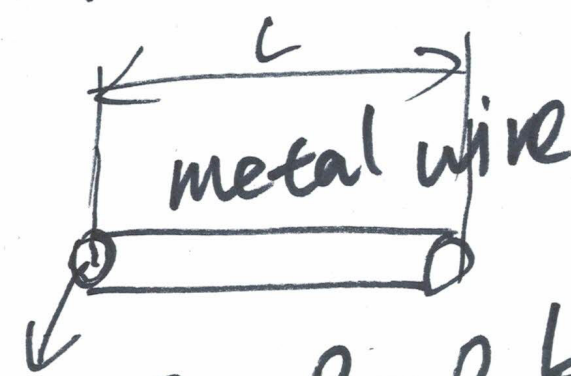
resistivity

magnitude of electron charge

conc. of electrons

conc. of holes

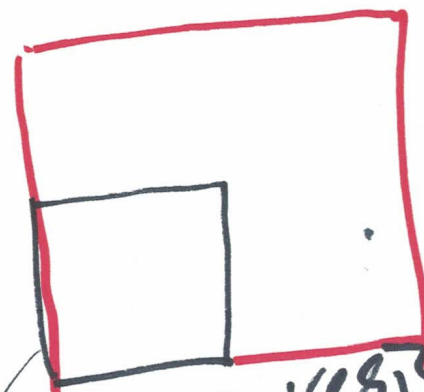
$= 1.6 \times 10^{-19}$ Coulomb



$$A = \pi r^2$$

$$R = \rho \frac{L}{A}$$

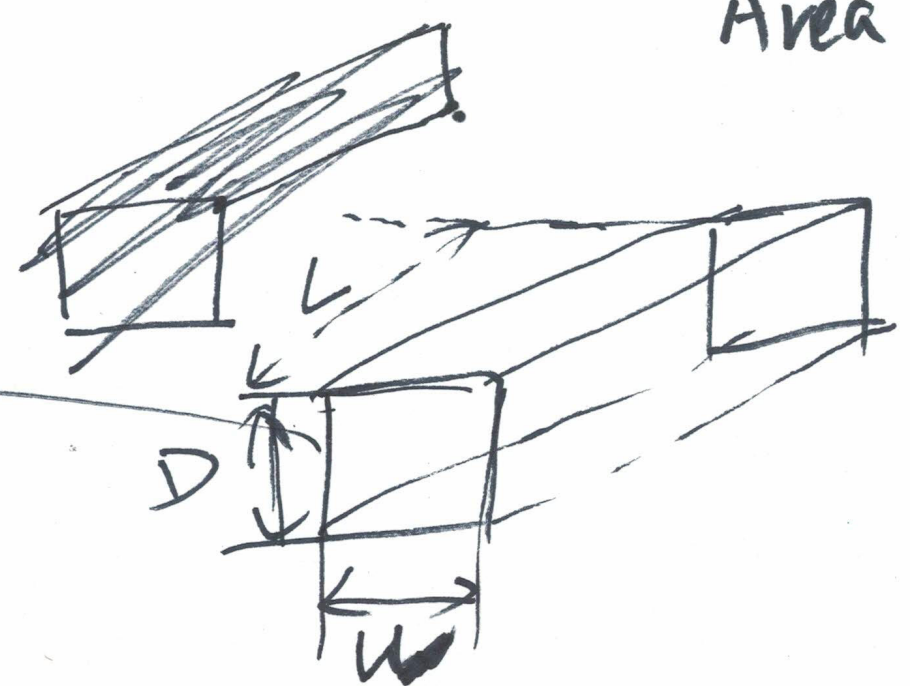
cross-sectional Area



Sheet Resistance

$$R_{n-well} = \frac{\rho L}{A} = \frac{\rho L}{W \cdot D}$$

$$= \rho \cdot \frac{L \times 2}{W \times 2} \cdot \frac{1}{D}$$



②

$$\textcircled{3} \quad \sigma = \frac{1}{\rho} = q(\mu_n \cdot n + \mu_p \cdot p)$$

Example:

Given: $p = n = n_i = 1.5 \times 10^{10} / \text{cm}^3$

$$\mu_n = 1350 \text{ cm}^2 / \text{V} \cdot \text{s}$$

$$\mu_p = 480 \text{ cm}^2 / \text{V} \cdot \text{s}$$

What is ρ ?

$$\rho = \frac{1}{q(\mu_n \cdot n + \mu_p \cdot p)}$$

unit:

$\Omega \cdot \text{cm}$

$$1.6 \times 10^{-19} \text{ C}$$

$\textcircled{3}$

Example:

p-type, $N_A = 10^{16} / \text{cm}^3$, $\mu_n = 1110 \text{ cm}^2 / \text{V}\cdot\text{s}$

$\mu_p = 400 \text{ cm}^2 / \text{V}\cdot\text{s}$, what is ρ ? (at room temp)

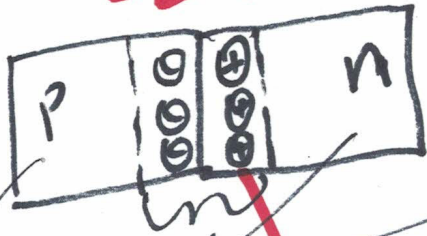
$$N_A = P_p = 10^{16} / \text{cm}^3$$

$$P_p \cdot n_p = n_i^2$$

$$n_p = \frac{n_i^2}{P_p} = \frac{(1.5 \times 10^{10})^2}{10^{16}} = \frac{2.25 \times 10^{20}}{10^{16}}$$

$$= 2.25 \times 10^4 / \text{cm}^3$$

④ The pn junction



I_s

I_D

depletion region

$I_s = I_D$ at equilibrium

Electrically neutral

charge movement stops at a specific thickness of the depletion region

⑤ current driven by the Electric field : I_s (drifting current)

----- concentration gradient : I_D

(diffusion current)

⑤

⑥ E / V_b : built-in voltage, Barrier voltage.

Si : 0.6 - 0.7 V at room temp

⑥